	Application No.	Applicant(s)
Notice of Allowability	10/509,370	SUGAWARA ET AL.
	Examiner	Art Unit
	Duy-Vu N. Deo	1792
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to RCE filed 10/31/07 and remarks filed 11/14/07.		
2. The allowed claim(s) is/are <u>16-19,23,25-28,32,42,45,54-56,58,64,65,71 and 72</u> .		
<ul> <li>3. ☐ Acknowledgment is made of a claim for foreign priority unallocation.</li> <li>a) ☐ All b) ☐ Some* c) ☐ None of the:</li> <li>1. ☐ Certified copies of the priority documents have</li> </ul>		
2. Certified copies of the priority documents have been received in Application No.		
3. Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.		
5. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached		
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).		
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.		
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Attachment(s) 1 ☐ Notice of References Cited (PTO-892)	5. Notice of Informa	I Patent Application
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summa	• •
<u> </u>	Paper No./Mail Date	
<ol> <li>Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date <u>11/27/07</u></li> </ol>	7. 🛛 Examiner's Amendment/Comment	
. ☐ Examiner's Comment Regarding Requirement for Deposit 8. ☒ Examiner's Statement of Reasons for Allowan		ment of Reasons for Allowance
of Biological Material	9.  Other	
	Duy-Vu N. Deo Primary Examiner 2/4/08	

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## **DETAILED ACTION**

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows: claims 66-70 have been withdrawn without traverse in the paper filed 10/3/06, they are canceled by the examiner.

Please amend claim 32 as: A process for forming an insulating film according to claim 25, which further comprises forming a High-k film after the treating.

## Allowable Subject Matter

2. The following is an examiner's statement of reasons for allowance: applicant's arguments that removal of hydrogen from nitride film forming plasma would change the basic principle under which the nitride film of Ohmi is formed and that a proposed based on a film forming step (without hydrogen) and subsequent hydrogen treating step is contrary to the teaching of Ohmi are found persuasive. Ohmi teaches that the hydrogen is essential and important during the process of forming the nitride film (paragraph 0076). Therefore, there is no suggestion of splitting the process of forming nitride of using a mixture of nitrogen and hydrogen into 2 steps of using nitrogen gas for nitrogen film forming step and hydrogen gas for the subsequent treating step or there is no suggestion that splitting this step into 2 steps would have the same results.

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Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Duy-Vu N. Deo whose telephone number is 571-272-1462. The examiner can normally be reached on Mon-Fri.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571-272-1465. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Duy-Vu N Deo Primary Examiner Art Unit 1792

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